

CLASSIFICATION SECRET/CONTROL - U.S. OFFICIALS ONLY
 SECURITY INFORMATION
 CENTRAL INTELLIGENCE AGENCY

25X1A

INFORMATION REPORT

REPORT NO [REDACTED]

CD NO

COUNTRY	East Germany	DATE DISTD	2/13/68 1003
SUBJECT	Production and Reorganization at Carl Zeiss Jena, 1953 - 1957	NO. OF PAGES	2
PLACE ACQUIRED	[REDACTED]	NO. OF ENCL'S LISTED BELOW	25X1A
DATE OF INFO	[REDACTED]	SUPPLEMENT TO REPORT NO	[REDACTED]

25X1X

1. It is planned to affiliate the Rathenow Optische Werke (ROW), Preußische Optische Werke (formerly Hildebrand) and the Dresdner Feinmechanische Werke (formerly Heyde) with Carl Zeiss, Jena, in such a manner that all of the research, development, production technology, and design-engineering work will be performed centrally at Carl Zeiss in Jena.

2. The planned breakdown of production by VEB Carl Zeiss Leibnitz (main enterprise) and attached plants in 1957 is:

	Floor space in square meters	Labor force in 1957	Labor force as of 1 March 1958
Jena, main plant		9 000	10 000
" , south plant	155 000	6 500	7 100
Seefeld, old plant	10 000	1 000	910
" , building 38 1/2	10 000	1 000	
Weimar, new plant	10 000		
" , old plant	3 000	1 200	1 200
Seebach	8 000	800	1 100
Bisfeld	3 000	300	300
Dresden Reich	5 000	500	500
Winterstein	1 000	100	100
Erfurt (Optima)	15 000	1 500	1 500
Total	220 000	21 900	27 000

Net production for 1957 (production of goods for sale): 160 million DM East.
 Gross production for 1957: 200 million DM East.

3. The planned production for 1958 by VEB Carl Zeiss, Jena (estimated good production is 106 million DM East, planned goods production is 114 million DM East) to be broken down according to individual plants as follows:

a. The main plant at Jena will produce scientific computers, high quality optical systems, surveying instruments, lenses for glasses, and precision measuring devices.

25X1A

CLASSIFICATION SECRET/CONTROL - U.S. OFFICIALS ONLY

SECRET/CONTROL - U.S. OFFICIALS ONLY

25X1A

- b. The south plant at Jena will produce photogrammetric instruments, astro-apparatus, special electrical instruments, optical systems, synthetic gems, and oscillator crystals. Apprentice training will also take place.
 - c. The old plant at Saalfeld will produce parts of simple camera objectives, optical systems, and individual and assembled parts for various precision instruments.
 - d. The plants at Weimar will produce sound motion picture apparatus in addition to other productions now being outlined.
 - e. The Seebach plant is preparing for the production of individual parts for precision instruments and during 1953 will produce sound-movie apparatus.
 - f. The plant at Eisfeld will do preparatory production 2/ for all other plants.
 - g. Special optical systems, principally for cameras, are planned for production at Dresden Reick.
 - h. The Winterstein plant will work on the dual-front production of high grade special optical systems.
4. The planned production for 1957 by VEB Carl Zeiss (approximately 160 million DM East) is to be assigned to individual plants as follows:
- a. Zeiss' main plant at Jena will be the scene of financial and general administration, research and development, design engineering offices, laboratories, and experimental shops. Scientific computers, high quality optical systems, surveying instruments, microscopes and optical apparatus, and possibly high grade military equipment will be produced at this plant.
 - b. The south plant at Jena will feature machine construction and repair, a foundry, pressure casting, carpentry, sheet metal, tool manufacturing, punching and gear wheel shops. Precision measuring devices, photographic instruments, astro-apparatus, military equipment (possibly), special electrical instruments, optical systems, lenses for glasses, synthetic jewels, and oscillator crystals are also slated for production at this plant.
 - c. Simple camera objectives and optical systems are to be produced at the old plant at Saalfeld.
 - d. Production of binoculars, telescopes, military equipment using optical systems (possibly) will be done at Saalfeld, building 38.
 - e. The Weimar and Seebach plants will produce sound motion picture apparatus and will conduct adjustments for precision instruments.
 - f. The Eisfeld plant will be the site of group assembly and preparatory production for other Zeiss plants.
 - g. Special optical systems, principally for cameras, are planned for production by the Dresden Reick plant.
 - h. The plant at Winterstein will feature dualfront production of high grade special optical systems.
 - i. Projectors, motion picture apparatus, and electrical instruments will be produced at the Erfurt (Optima) plant.

25X1A

Comment:

- 1/ Saalfeld, Bau 38, requisitioned now by Wismut AG and utilized for billeting miners, is being vacated.
- 2/ Apparently rough machining and other preliminary production.

SECRET/CONTROL - U.S. OFFICIALS ONLY